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Wettability determined by angle of contact measurements for electrodeposited Cu₂O thin films with sulphur based surface treatments or chlorine doping

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The angle of contact (α) was measured for Cu₂O thin films electrodeposited on Ti substrates with either chlorine doping, or with its surface modified using sulphidation followed by surface passivation. The fabrication of *n*-Cu₂O films were done in an acetate bath containing aqueous solutions of 0.1 M sodium acetate and 0.01 M cupric acetate at 60°C. Sulphidation of *n*-Cu₂O films was achieved by applying a thin layer of an aqueous solution of 0.01 M Na₂S on the surface of the film and allowing to react with the film at 200°C. Subsequently, exposure of the sulphided film surface to (NH₄)₂S passivated the film surface. Chlorine doping was done on *p*-Cu₂O films fabricated using electrodeposition. The amount of chlorine doping was varied in *p*-Cu₂O films deposited in a lactate bath containing an aqueous solution of lactic acid (3 M), cupric sulphate (0.45 M) and sodium hydroxide by varying CuCl₂ concentrations. Using a custom built experimental setup supplemented by image processing software, α measurements of distilled water on the deposited thin films were made using the sessile drop method. Film morphology was revealed by scanning electron micrographs (SEM), while x-ray diffraction (XRD) spectroscopy was used to probe the structural properties of the films. For distilled water, bare Cu₂O films independent of its conductivity type was found to be non-wetting ($\alpha \geq 90^\circ$), exhibiting non-polar surface properties of the film. Sulphidation using Na₂S made the surface of the *n*-Cu₂O films highly wetting ($\alpha < 30^\circ$) as result of the polar nature and the decreased roughness of the sulphided film surface. With subsequent passivation of these sulphided films, the resulting less polar film surface with re-emerged roughness made the films partially wetting ($90^\circ > \alpha \geq 30^\circ$). With increased chlorine doping it was found that α measurements increased making the film surfaces more non-wetting for distilled water. It was also noted that when the morphological structures of the films were in the nano-scale the surfaces were more non-wetting in nature. These observations show that surface modifications and doping not only influence the charge transport properties of Cu₂O thin films, but also affects the wettability which is an important consideration in the context of utilizing them as sensors for detecting molecules having varying charge polarization ability.

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